Symposium (Oral) | Symposium | Create a path of future semiconductor devices by new materials and processes

## [19p-233-1~12]Create a path of future semiconductor devices by new materials and processes

Akio Ohta(Nagoya Univ.), Noriyuki Taoka(AIST) Wed. Sep 19, 2018 1:30 PM - 5:50 PM 233 (233)

 $\triangle$ : Presentation by Applicant for JSAP Young Scientists Presentation Award

▲ : English Presentation

▼: Both of Above

No Mark: None of Above

1:30 PM - 1:35 PM

## [19p-233-1]Opening remarks

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Keywords:Semiconductor